

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

May 16, 2024

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa

LG633433769

Report verification at igi.org

PROPORTIONS

Medium

65%

12%

50.5%

65.9%

Long

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

IF VS 1-2 VS 1-2 SI 1-2 I 1-3

Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

Sample Image Used

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EMERALD CUT

1.10 CARAT

E

VS 2

EXCELLENT

EXCELLENT

NONE

IGI LG633433769

Medium

65%

12%

50.5%

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IGI

INTERNATIONAL GEMOLOGICAL INSTITUTE

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EMERALD CUT

7.00 X 4.93 X 3.25 MM

1.10 CARAT

E

VS 2

65.9%

65%

Medium

Long

EXCELLENT

EXCELLENT

NONE

IGI LG633433769

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